

Thermal bump removal by designing an optimised crystal shape

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French CRG-IF BM32 at ESRF

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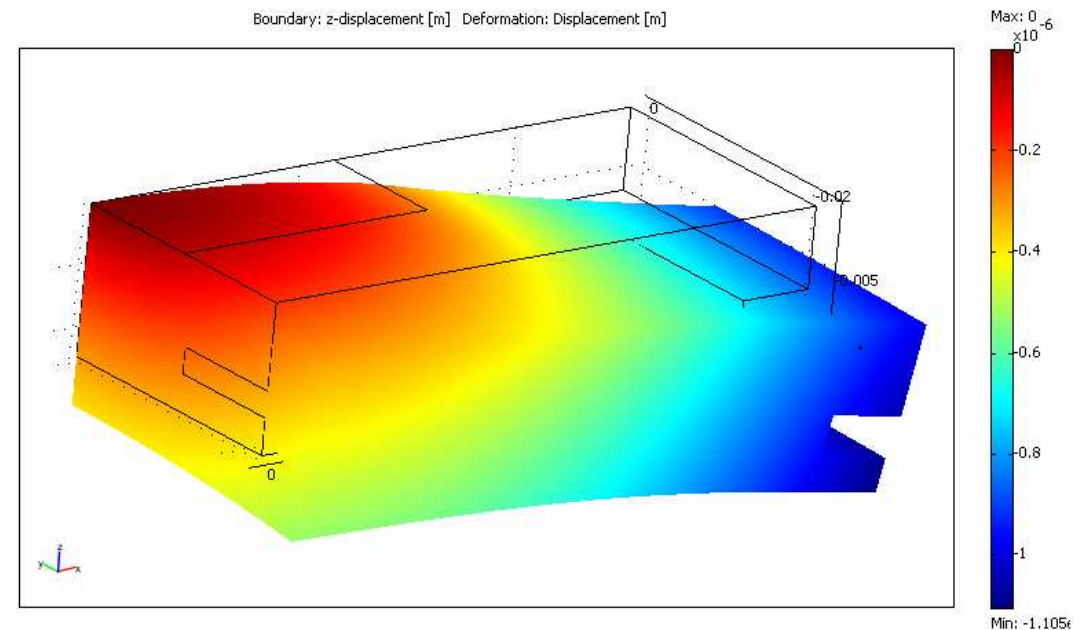
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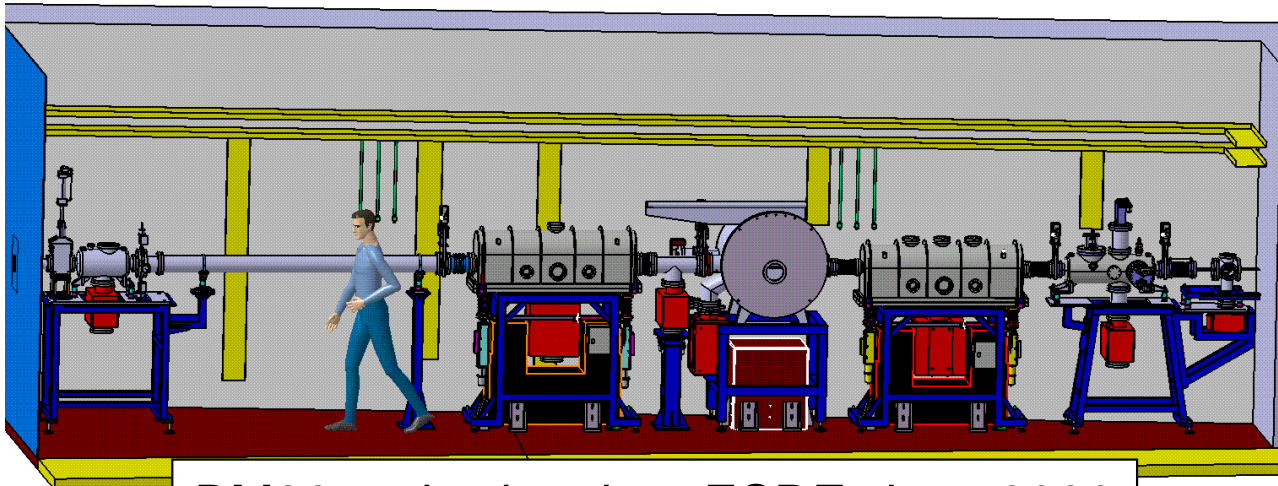


Outline

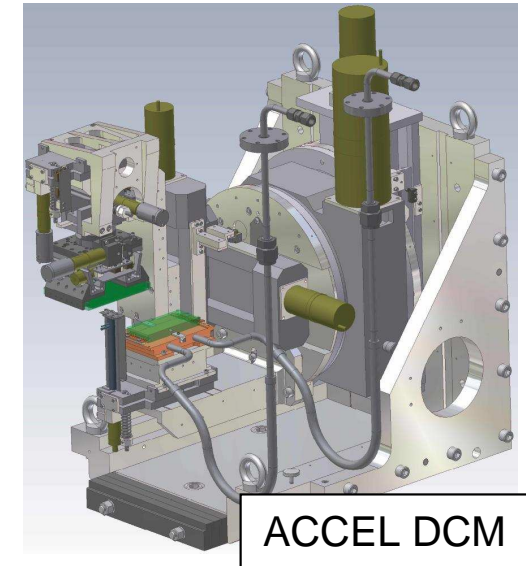
- Motivations
- Modelling
- Results
- Conclusions



Motivations

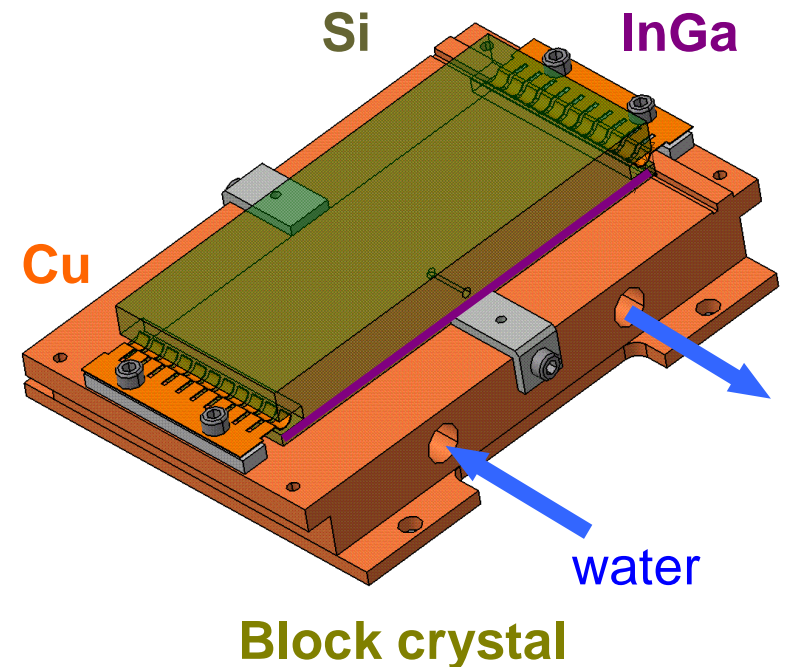


BM32 optics hutch at ESRF since 2006



ACCEL DCM

- *Bending Magnet at ESRF*
 - heat power : 300W
 - acceptance: horiz. $>1.5\text{mrad}$, vert. 0.1 mrad
- *New Double Crystal Monochromator*
 - Si(111)
 - from 5 to 30 keV
- *keep cheap and simple cooling design*
 - water (avoid LN2)
 - indirect cooling (simple + less vibrations)

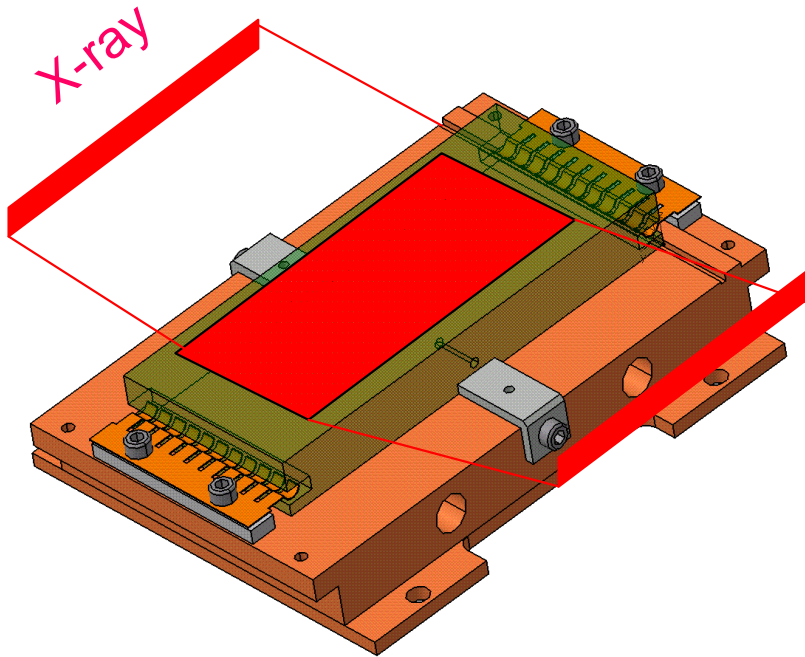


Modelling : FEA - Heat

- **Heat source:**

- 2D domain incoming power
- ~ 100-150 W on 40x50 mm
- ~ 50-130 mW/mm² (on mono)

- Spatial distribution (uniform, gaussian-like)
- current in storage ring
- crystal inclination (working energy)
- Slits aperture (h_{xv}), illuminated area

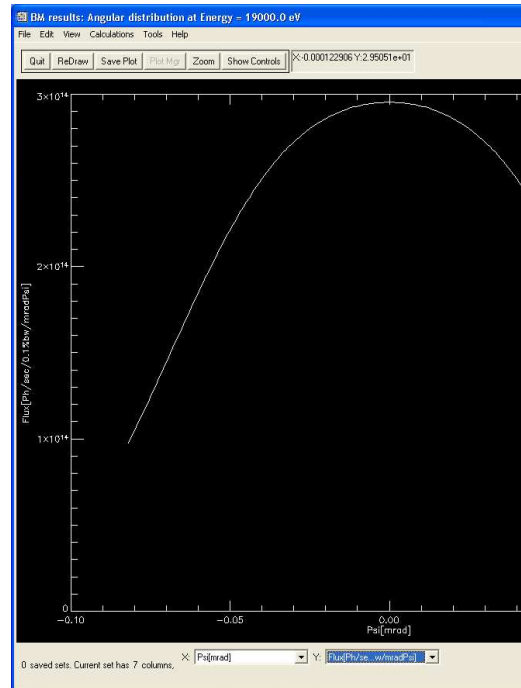


- **Cooling power:**

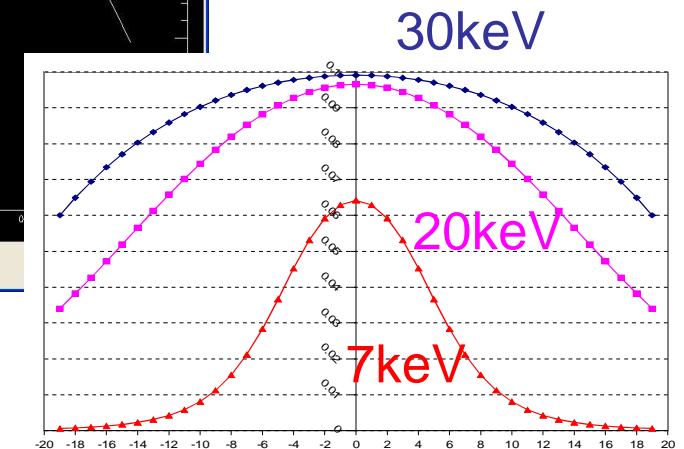
- convective transfer: water/Cu
- h = 5000W/mm²/K
- heat resistance Si/InGa/Cu

XOP

E=6.04 GeV H accept= 2.09 mrad
 R=25m (mono. 26.9m
 B=0.8T Slits 23.9m)



0.1 W/mm_v²



Modelling : FEA - deformation

Get at (reflective) domain surface:

uz vertical displacement along z => derivative of uz along y (// x-ray beam)

=> μ longitudinal slope errors

FEA with COMSOL multiphysics
(ex FEMLAB)

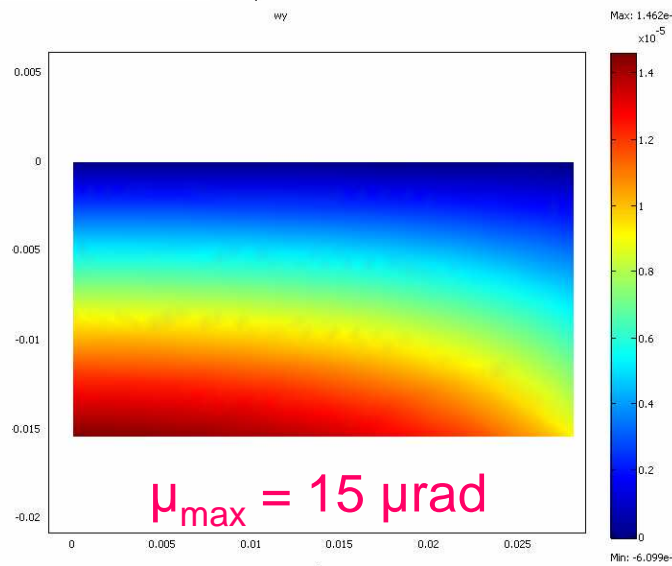
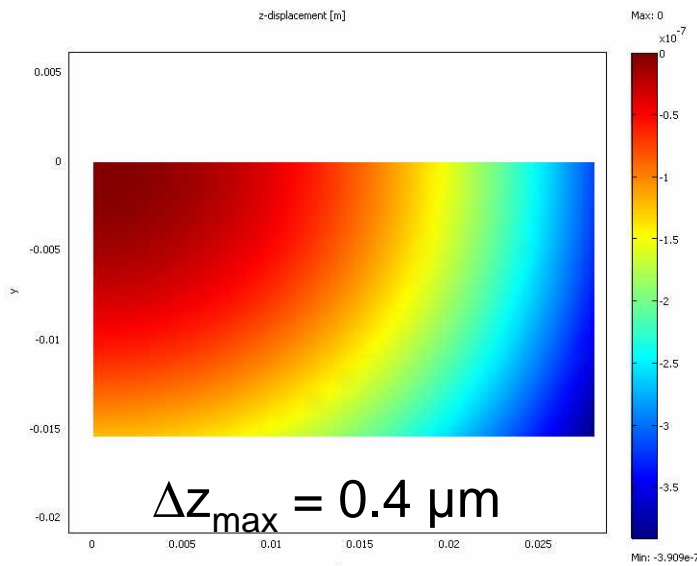
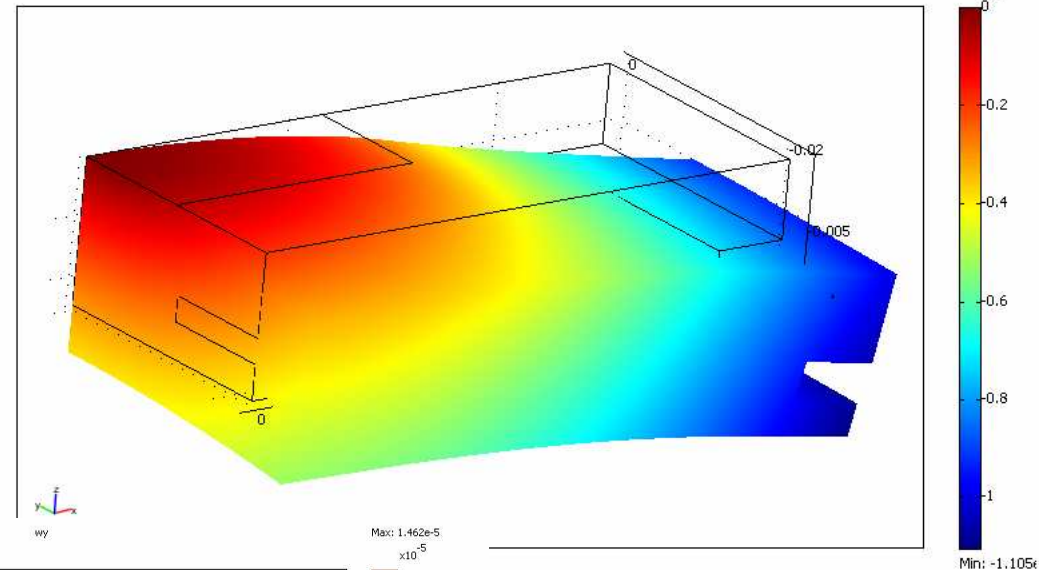
Standard block Si crystal

$E = 18\text{keV}$

$\Delta\omega = 16 \mu\text{rad}$

$I = 200\text{mA}$

Boundary: z-displacement [m] Deformation: Displacement [m]

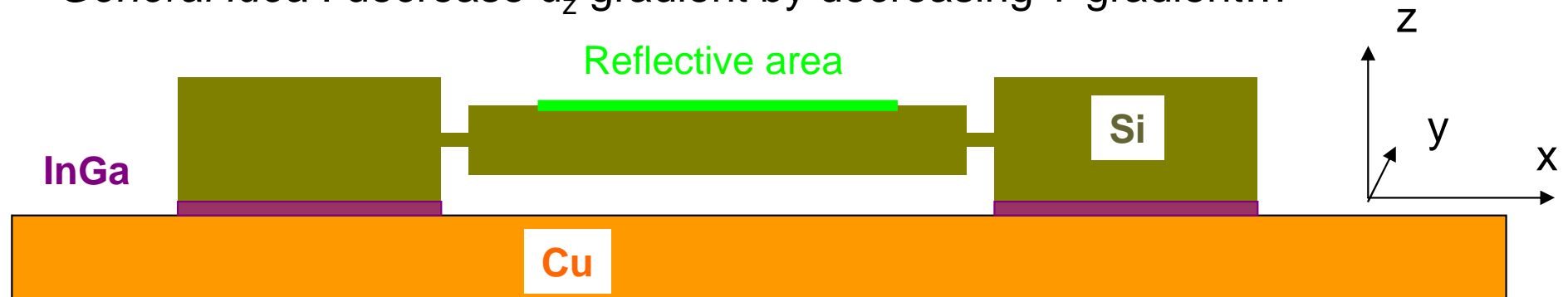


$R_{\text{int}} = 50\%$

Less than to 25%
with $I = 350\text{mA}$

Modelling : design of an optimised shape

- *Previous works* : side cooling better than bottom cooling
- *General idea* : decrease u_z gradient by decreasing T gradient...



Water cooling

- *First simulations* : possibility to reverse the bump curvature !
- *For a given heat load*: possibility to remove longitudinal u_z gradient (smooth profile)
- *add deformation sources*
- Constraints to the design:
 - several optics configurations
 - limited crystal size

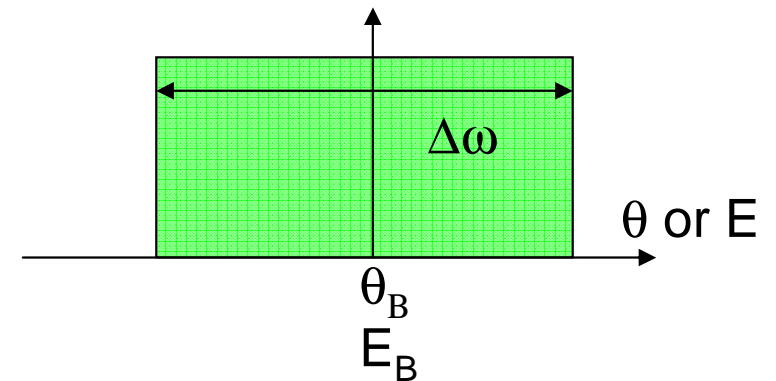


Strain and **temperature gradient** are outside the reflective domain

Reflectivity Model - surface bump

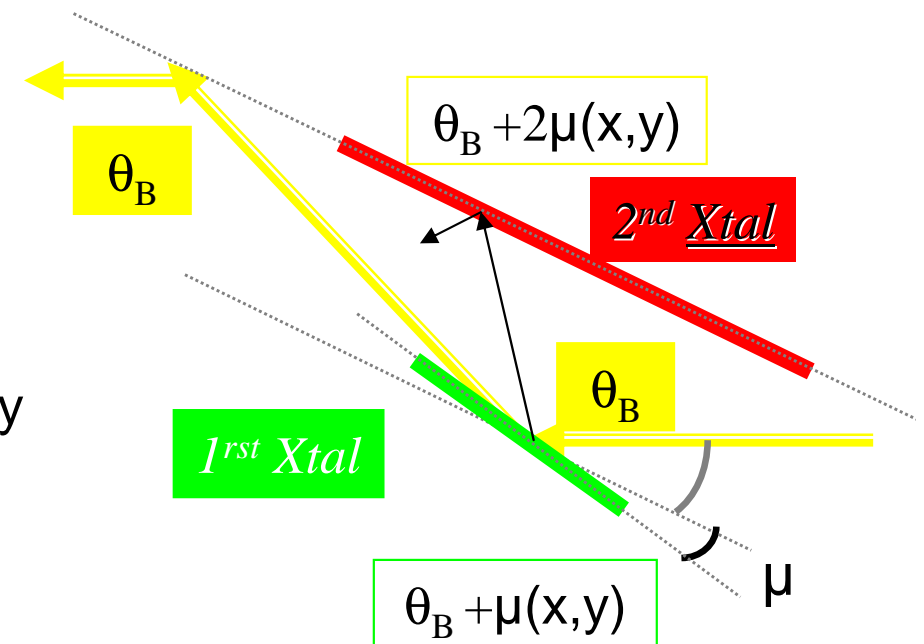
Simple Model: μ : Slope error at (x,y) on 1st crystal / flat 2nd crystal
 $\Delta\omega$: Darwin width

Bragg reflectivity ~ gate function $\Delta\omega$ or ΔE width



DCM reflectivity per unit area: $R(x,y)$

$$R(x,y) = \begin{cases} 1 - |\mu_{(x,y)}|/\Delta\omega & \text{if } |\mu_{(x,y)}| < \Delta\omega \\ 0 & \text{else} \end{cases}$$



Integrated reflectivity : $R_{\text{int}} = \int_{\text{area}} R_{(x,y)} dx dy$

- Objective function to optimise
- two inputs:
 - local slope error $\mu(x,y)$ from FEA
 - Darwin width $\Delta\omega$ (working energy)

Reflectivity Model - thermal lattice expansion

Two origins of lattice planes strain at illuminated surface:

- slope errors (longitudinal z-displacement gradient)
- thermal lattice spacing expansion

$$\Delta\theta_B = \alpha_{\text{expansion}} \cdot \tan\theta_B \Delta T = \mu_{\text{th}}$$

@20 keV, $\alpha_{\text{Si}} = 2.66 \cdot 10^{-6} \text{ K}^{-1}$

$\Delta T = 1^\circ\text{C} \Leftrightarrow \Delta\theta_B = 1/4 \text{ } \mu\text{rad}$

$\Delta T = 60^\circ\text{C} \Leftrightarrow \Delta\theta_B = \Delta\omega$

- If $T_1(x,y)$ uniform \Rightarrow perfect tuning with tilted 2nd Xtal by $\Delta\theta_B$ with $\Delta T = T_2 - T_1$
- if $T_1(x,y)$ non uniform \Rightarrow best tuning with tilted 2nd Xtal by $\Delta\theta_B$ with $\Delta T = T_2 - \text{mean}(T_1)$
equivalent slope error $\sim \mu = \alpha_{\text{expansion}} \cdot \tan\theta_B \Delta T_{\text{Max}}/2$

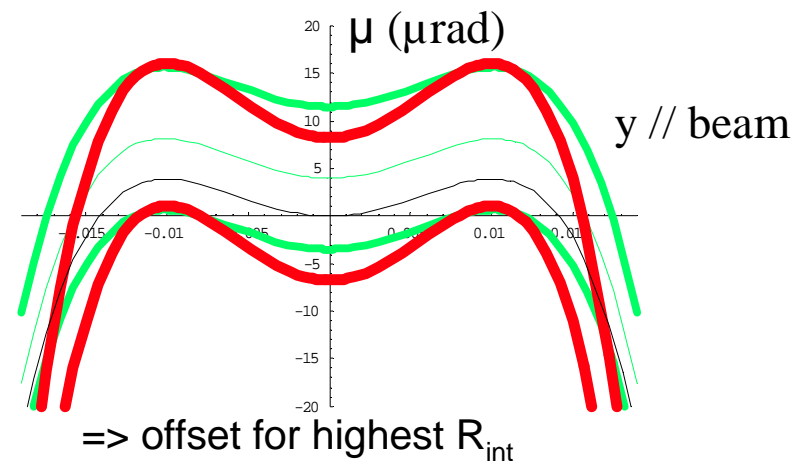
For our heat load range, d-spacing variation can be omitted

- A more accurate computation can be done:

$$\mu_{\text{th}} = (T_2 - T_1(x,y)) \cdot \alpha_{\text{Si}} \cdot \tan\theta_B$$

Gate function Xtal 1 with $\mu + \mu_{\text{th}}$

Gate function Xtal 2 with $2\mu + \text{offset}$

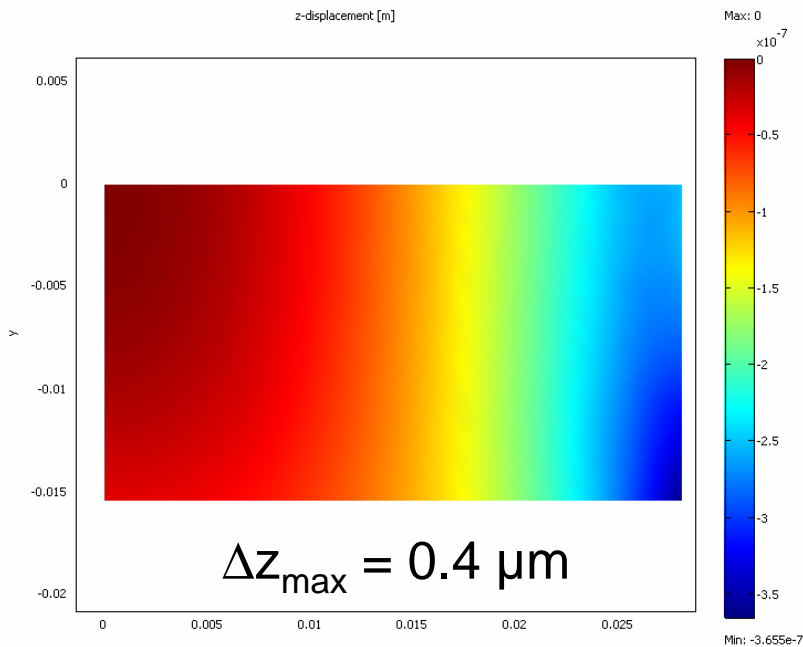
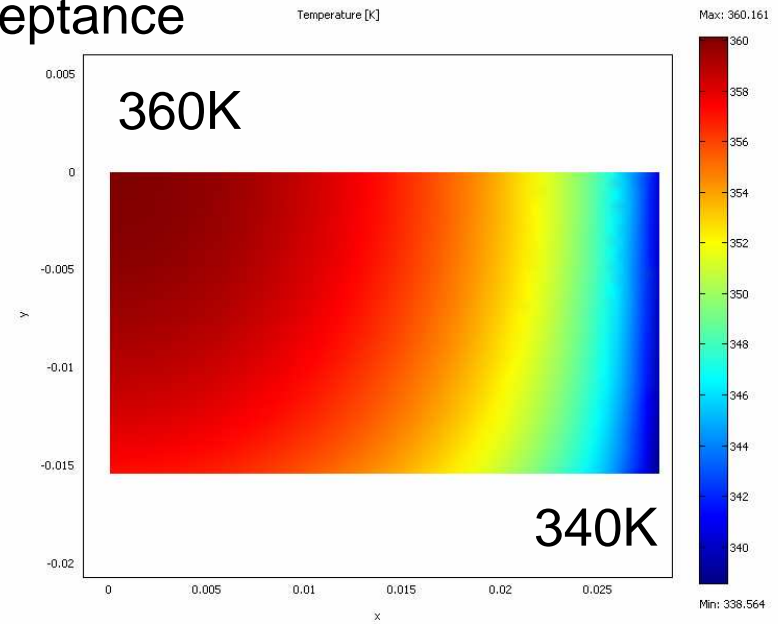


Results

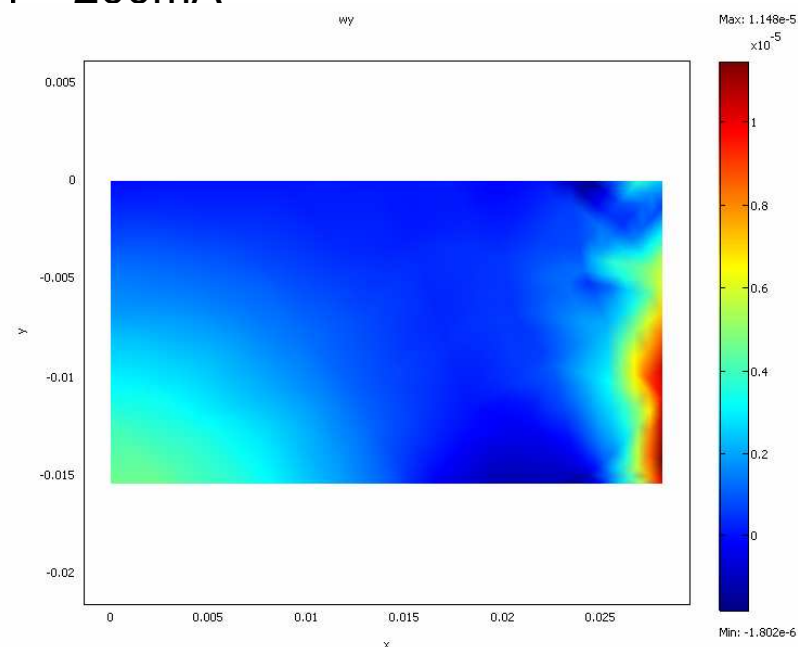
Optimised shape for 3 Energies X 3 horiz. acceptance



$E = 18\text{keV}$
 $\Delta\omega = 16 \mu\text{rad}$
 $I = 200\text{mA}$



Gradient is along x !

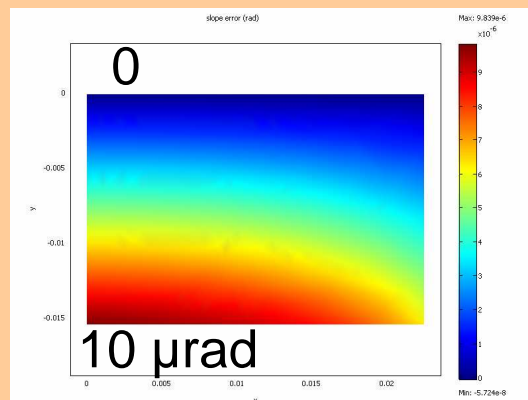
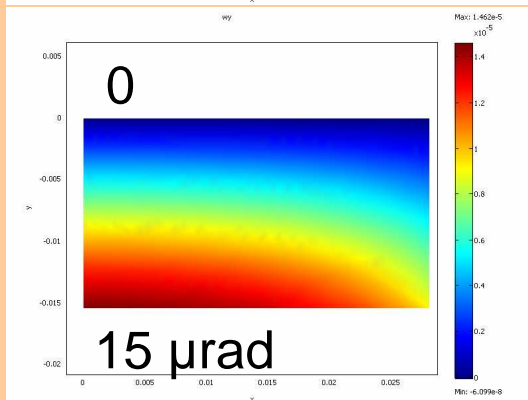
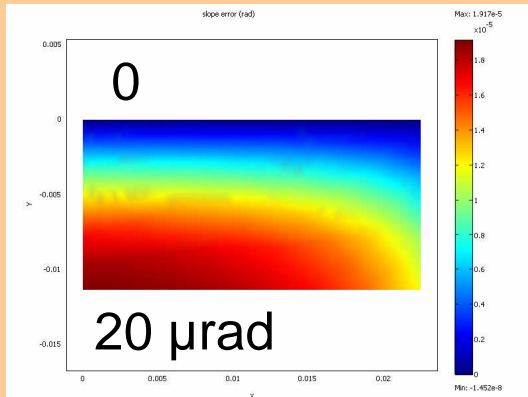


Rint = 90%

$\mu = -2 \text{ to } 11 \mu\text{rad}$ $\mu_{\text{mean}} = 2 \mu\text{rad} !$

Results: comparison old-new crystal

Old Xtal



8 keV 40x5 mm $\Delta\omega = 40 \mu\text{rad}$

Total power 129.25 W

in rectangle $h= 45.02 \text{ mm}$ and $v= 22.64 \text{ mm}$ on monochromator
mean power density 0.127 W/mm^2 (mono), 0.5 W/mm^2 (HxV)

18 keV 50x3 mm $\Delta\omega = 16 \mu\text{rad}$

Total power 122.8 W

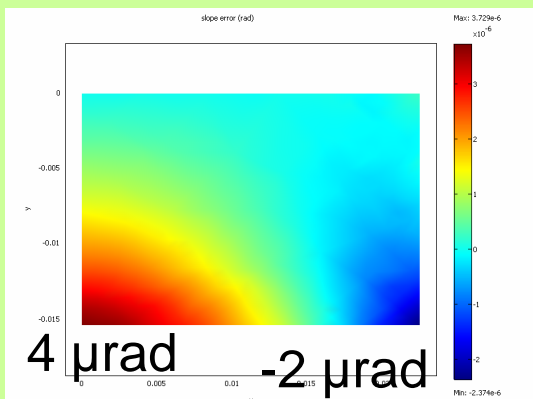
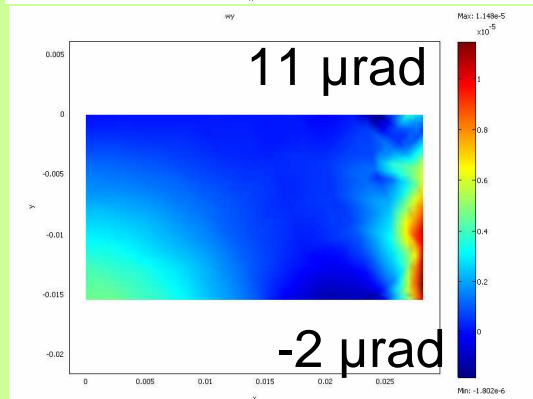
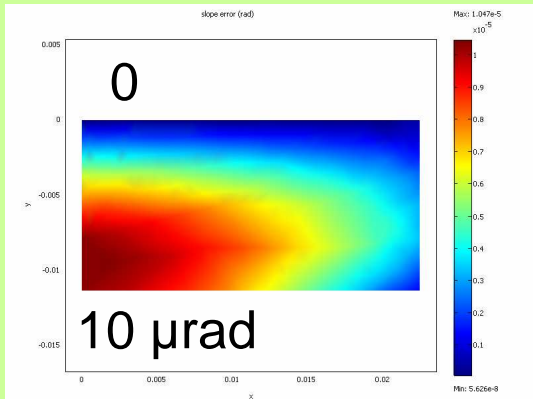
in rectangle $h= 56.28 \text{ mm}$ and $v= 30.36 \text{ mm}$ on monochromator
mean power density 0.072 W/mm^2 , 0.1 W/mm^2 (HxV)

27 keV 50x3 mm $\Delta\omega = 10 \mu\text{rad}$

Total power 98.24 W

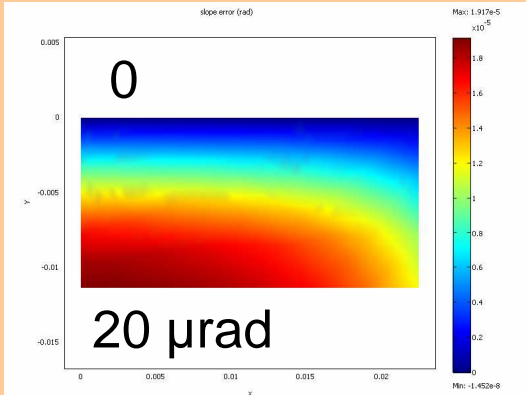
in rectangle $h= 45.02 \text{ mm}$ and $v= 45.55 \text{ mm}$ on monochromator
mean power density 0.048 W/mm^2 or 0.66 W/mm^2 (hxv)

New Xtal



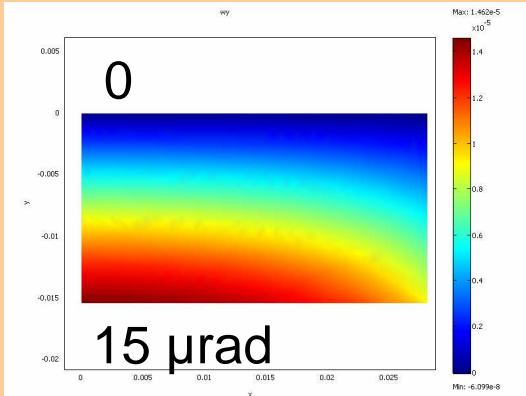
Results: comparison **Exp.** - FEA

Old Xtal



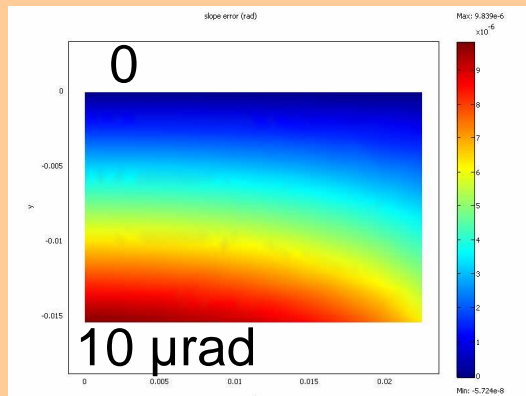
8 keV 40x5 mm $\Delta\omega = 40 \mu\text{rad}$

$R_{\text{int}}=70\%$ $R_{\text{int}}=85\%$
 0.5 10^{11} ph/s/200mA 0.7



18 keV 50x3 mm $\Delta\omega = 16 \mu\text{rad}$

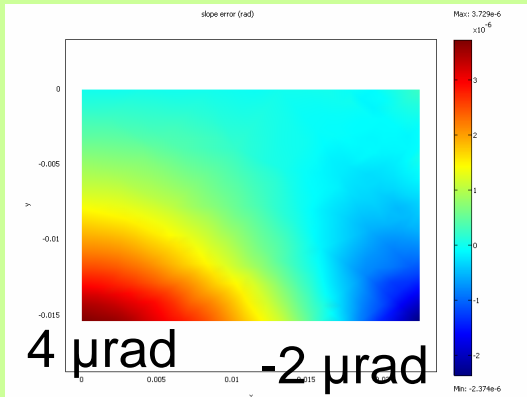
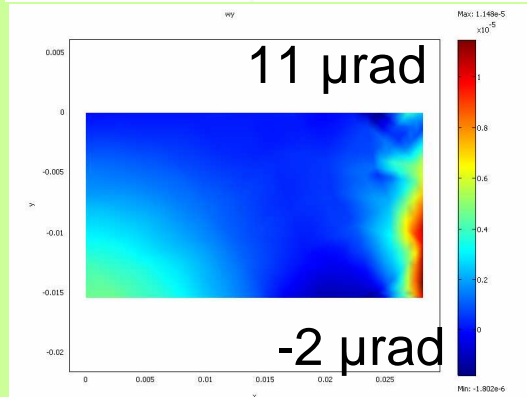
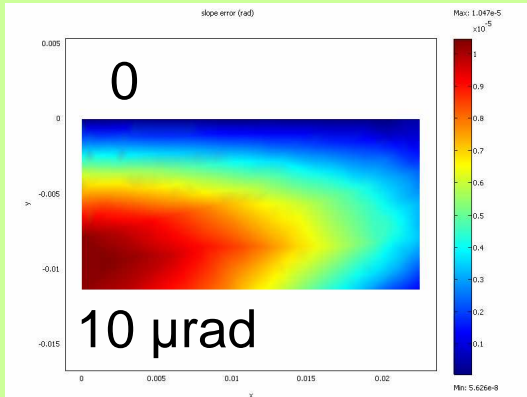
$R_{\text{int}}=56\%$ $R_{\text{int}}=90\%$
 4.32 8.0



27 keV 50x3 mm $\Delta\omega = 10 \mu\text{rad}$

$R_{\text{int}}=56\%$ $R_{\text{int}}=92\%$
 5.36 8.74

New Xtal



Conclusions

- Optimised crystals mounted on BM32 and BM02 at ESRF
- Photons flux at sample is very close to the theoretical flux
- FEA predicts high R_{int} even for higher storage ring current

Advantages

- Longitudinal bump removed
- Self-tuning crystal
- For one optics configuration => it should exist an optimised shape
- Cheap (indirect cooling + water)
- Simple to design & simple iterative converging methodology
- Standard manufacturing and tailoring
- Easy to mount & not sensitive to mounting defaults

Drawbacks (?)

- Increase of temperature (but whole setup might be cooled down anyway)
- Weak sagittal bump (but could be compensated)

Outlook

- Automatic iterative method, use ray-tracing method
- Install on other BM beamline @ ESRF, SOLEIL (DIFFABS,...), etc...
- Apply on Ge/Si (Smart Cut)
- Apply on other reflective surfaces:
 - monochromator with higher power load (wiggler, undulator)
 - mirror
 - other spectral range (laser)

Thank you for your attention

